

Sheet 1 of 1

Form PTO-1449 U.S. Department of Commerce (Modified) Patent and Trademark Office <div style="text-align: center;">INFORMATION DISCLOSURE STATEMENT BY APPLICANT</div>										Attorney Docket No. S-100,580		Serial No. 			
37 CFR 1.98(b)										Applicant(s) Yixiang Duan		Filing Date 		Group 	

U.S. PATENTS DOCUMENTS														
EXAMINER INITIAL	PATENT NUMBER									ISSUE DATE	PATENTEE	CLASS	SUB CLASS	FILING DATE
b			5	9	6	1	7	7	2	12/5/99	Selywn	156	345.39	January 23, 1997
↓			5	4	1	4	3	2	4	5/9/95	Roth et al.	315	111.21	October 29, 1993
↓			5	4	5	6	9	7	2	10/10/95	Roth et al.	442	301	May 28, 1993

FOREIGN PATENT DOCUMENTS																
EXAMINER INITIAL	PATENT NUMBER									ISSUE DATE	COUNTRY	CLASS	SUB CLASS	Translation YES NO		

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)													

EXAMINER:	DATE CONSIDERED: 9/27/06
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*EXAMINER: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



Revised 05/01/03

Sheet 1 of 1

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(Modified) Patent and Trademark Office

Attorney Docket No.

Serial No.

S-100,580

10/616,610

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

Applicant(s)

Yixiang Duan

Filing Date
7/9/2003

Group

37 CFR 1.98(b)

U.S. PATENTS DOCUMENTS

EXAMINER INITIAL	PATENT NUMBER								ISSUE DATE	PATENTEE	CLASS	SUB CLASS	FILING DATE
1		6	1	2	4	5	9	2	09/26/00	Spangler	250	287	03/18/98

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	PATENT NUMBER								ISSUE DATE	COUNTRY	CLASS	SUB CLASS	Translation YES NO	

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)

1	Yixiang et al., "Pulsed, Atmospheric Pressure Plasma Source for Emission Spectrometry," US Patent Application, SN: 09/998,273, Filed November 30, 2001.

EXAMINER:

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9/27/06

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